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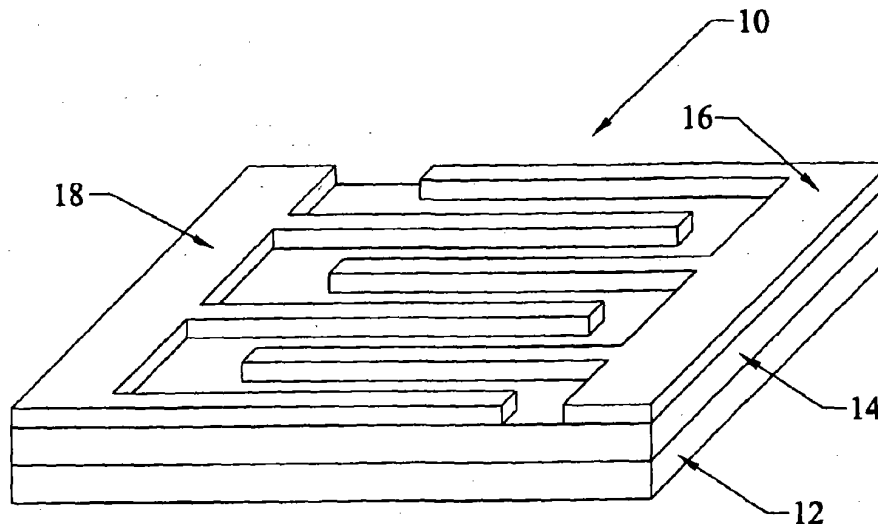
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(54) Title: ELECTRONIC AND OPTICAL MATERIALS



(57) Abstract: Epitaxial and reduced grain boundary materials are deposited on substrates for use in electronic and optical applications. A specific material disclosed is epitaxial barium strontium titanate (14) deposited on the C-plane of sapphire (12).

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